

## UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D.C. 20231
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/044,009	01/11/2002	Susan A. Alie	Analog 5911	8144	
75	90 04/23/2003				
Samuels, Gauthier & Stevens LLP Suite 3300 225 Franklin Street			EXAMINER		
			LE, THAO X		
Boston, MA 02					
boston, whi o			ART UNIT	PAPER NUMBER	
			2814		
			DATE MAILED: 04/23/2003	DATE MAILED: 04/23/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	*
	10/044,009	ALIE ET AL.	•
Office Action Summary	Examiner	Art Unit	
	Thao X Le	2814	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet wit	th the correspondence address	s
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO  - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a  - If NO period for reply is specified above, the maximum statutory per  - Failure to reply-within the set or extended period for reply will, by state - Any reply received by the Office later than three months after the maximum days after the	N. R 1.136(a). In no event, however, may a re- reply within the statutory minimum of thirty riod will apply and will expire SIX (6) MON atute, cause the application to become AB.	eply be timely filed  (30) days will be considered timely.  THS from the mailing date of this commun  ANDONED (35 U.S.C. § 133).	nication.
1) Responsive to communication(s) filed on <u>(</u>	09 April 2003 .		
2a)⊠ This action is <b>FINAL</b> . 2b)□	This action is non-final.		
3) Since this application is in condition for allo closed in accordance with the practice und			erits is
Disposition of Claims			
4) Claim(s) <u>1-8,23-26,30 and 31</u> is/are pendir	•		
4a) Of the above claim(s) is/are without	drawn from consideration.		
5) Claim(s) is/are allowed.			
6) Claim(s) <u>1-8,23-26,30 and 31</u> is/are rejected	d.		
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and	d/or election requirement.		
Application Papers	_		
9) The specification is objected to by the Exam			
10) The drawing(s) filed on is/are: a) □ ac	•		
Applicant may not request that any objection to	= ' '	• •	
11) The proposed drawing correction filed on		sapproved by the Examiner.	
If approved, corrected drawings are required in	• •		
12) The oath or declaration is objected to by the	Examiner.		
Pri rity under 35 U.S.C. §§ 119 and 120			
13) Acknowledgment is made of a claim for fore	eign priority under 35 U.S.C. §	119(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☐ None of:			
<ol> <li>Certified copies of the priority docume</li> </ol>	ents have been received.		
2. Certified copies of the priority docume	ents have been received in Ap	plication No	
Copies of the certified copies of the paper application from the International     See the attached detailed Office action for a limited page.	Bureau (PCT Rule 17.2(a)).	_	9
14) Acknowledgment is made of a claim for dome	•		ication)
a)  The translation of the foreign language	provisional application has be	en received.	ication).
15) Acknowledgment is made of a claim for dome	estic priority under 35 U.S.C. §	§§ 120 and/or 121.	
Attachment(s)	_		
Notice of References Cited (PTO-892)	5) Notice of In	ummary (PTO-413) Paper No(s) formal Patent Application (PTO-152) ·	

Application/Control Number: 10/044,009

Art Unit: 2814

#### **DETAILED ACTION**

# Response to Amendment

1. Applicant's request for reconsideration of the finality of the rejection of the last Office action is persuasive and, therefore, the finality of that action in Paper No 9 is withdrawn. A new final Office Action is based on the amendment filed on 12/24/02 in Paper No 8.

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 1-2, 4-6 and 8 are rejected under 35 U.S.C. 102(e) as being anticipated by US Pub No. 2002/0179921 to Cohn.

Regarding to claim 1, Cohn discloses a metallization stack in an integrated MEMS device [0145]-[0156] comprising: a silicide layer [0152] formed on a semiconductor substrate [0146] of the integrated circuit device, a titanium-tungsten layer [0153] formed directly on silicide layer to operatively contact an electrically conductive in the semiconductor substrate of the integrated MEMS device, a conductive layer [0154] formed over the titanium-tungsten layer.

Regarding to claims 2, Cohn discloses the metallization stack wherein electrically conductive structure is an active silicon element.

Regarding to claims 4-6, 8, Cohn discloses the metallization stack wherein the portion platinum layer [0154] wiring formed on the insulating film (optionally SiN) [0148], wherein the metallization stack is the optical MEMS or Bio-MEMS device [0004].

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

3. Claims 3, 7, 23-26, 30-31 are rejected under 35 U.S.C. 103(a) as being unpatentable over US Pub No. 2002/0179921 to Cohn in view of US 6096629 to Tsai et al.

Regarding to claims 3, 23-24, 30-31, Cohn discloses metallization stack wherein the semiconductor substrate has an insulating film (optionally SiN) [0148] formed thereon, wherein the portion platinum layer [0154] wiring formed on the insulating film (optionally SiN) [0148] and on titanium-tungsten layer, wherein the integrated MEMS is an optical MEMS [0004].

Application/Control Number: 10/044,009

Art Unit: 2814

-2

But Cohn does not explicitly disclose the insulating film has a contact hole formed therein, the contact hole exposes a portion of the surface of the semiconductor substrate at a bottom of the contact hole and silicide is formed only on the exposed portion of the surface of the semiconductor substrate, and wherein the silicide layer is platinum silicide layer

However, Tsai reference discloses the metallization stack wherein the semiconductor substrate 10/12 has an insulating film 14, column 5 line 20, formed thereon, the insulating film has a contact hole 13, fig. 3, formed therein, the contact hole exposes a portion of the surface of the semiconductor substrate at a bottom of the contact hole and platinum silicide 28 is formed only on the exposed portion of the surface of the semiconductor substrate, fig. 5. At the time the invention was made; it would have been obvious to one of ordinary skill in the art to use the contact holes teaching of Tsai with Cohn, because such it would have provided a low contact leakage Schottky diode contacts within microelectronics fabrication as taught by Tsai, column 1 line 6-12.

Regarding to claim 7, Cohn does not expressly disclose the metallization stack wherein the platinum layer forms a corrosive resistant electrode.

However, when the claimed and the prior art products are identical or substantially identical in structure or composition, or are produced by identical or substantially identical processes, a *prima facie* case of either anticipation or obviousness has been established. *In re Best*, 195 USPQ 430, 433 (CCPA 1977).

Regarding to claims 25-26, the processing steps 'depositing Pt', 'depositing an oxide', removing an oxide mask', 'removing the Pt', 'removing remaining hard mask', 'removing Pt by

Art Unit: 2814

sputtering etching' in claims 25-26 do not carry weight in a claim drawn to structure. In re Thorpe, 277 USPQ 964 (Fed. Cir. 1985).

## Response to Arguments

4. Applicant's arguments with respect to claims 1-8, 23-26, and 30-31 have been considered but are most in view of the new ground(s) of rejection.

## Conclusion

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Application/Control Number: 10/044,009

Art Unit: 2814

Page 6

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thao X Le whose telephone number is 703-306-0208. The examiner can normally be reached on M-F from 8:00 AM - 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M Fahmy can be reached on 703-308-4918. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

Thao X. Le April 20, 2003

PHAT X. CAC PRIMARY EXAMINER